

Metrology for trace water in ultra-pure process gases: goals and challenges



Vito C. Fernicola, INRIM GAS Analysis 2022, 17-20 May, Paris



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Semiconductor manufacturing - demands for UHP process gases with total impurities as low as few ppb.

Organic electronics - highly moisture-sensitive, needs ultra-dry manufacture and vapour barrier coatings.

UHP bulk process gases - need to be manufactured with total impurities below 1 ppm in volume (grade N6.0 or better).

Utility power generation - needs dry hydrogen (<5 ppm) to cool high-efficiency stationary generators.

Instrument manufacturers - need traceable standards to support their product development while endusers rely on them for instrumental testing and calibration.









Water vapour is the single largest matrix contaminant in ultra-high purity (UHP) process gases used in key technology areas.

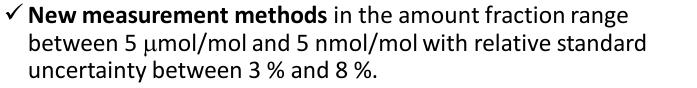
Its measurement presents great challenges to both gas manufacturers and analytical instrument makers.

- To fill the gap between the demand of traceable measurement and the available humidity standards currently limited at $\sim 1 \mu$ mol/mol.
- To develop traceable and improved methods for trace water measurement relevant to the production and use of UHP gases.
- To facilitate the uptake of the technology by the gas industry supply chain through exploiting knowledge and services developed in an European-wide metrology infrastructure.



PROMETH20 objectives





- ✓ New primary standards for trace water vapour in N₂, Ar and H₂ down to 5 nmol/mol (or -105 °C frost point temperature) at pressures up to 1 MPa.
- ✓ New data and correlation equations of water vapour enhancement in N₂, Ar and H₂ in the temperature range from -30 °C to -90 °C and pressures up to 1 MPa.
- ✓ Demonstration at selected industrial settings with real-time measurements and on-site calibrations.
- ✓ A toolkit of metrological solutions for robust measurement traceability in the production of ultra-pure process gases, by leveraging on improved standards and range-extended measurement capabilities.





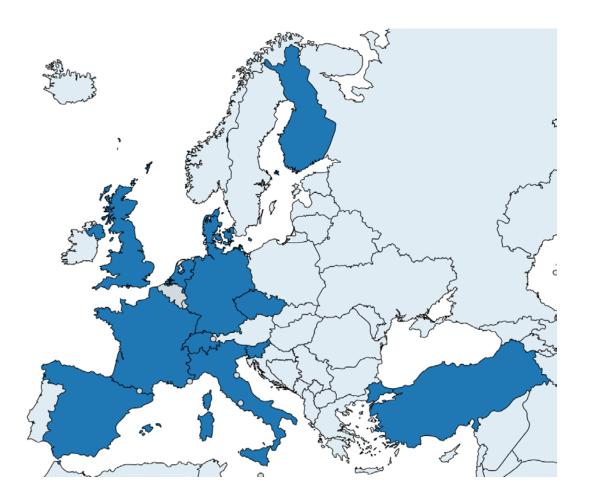




The Consortium



RIVOIRA





19 partners from 12 countries \rightarrow 240 person-months

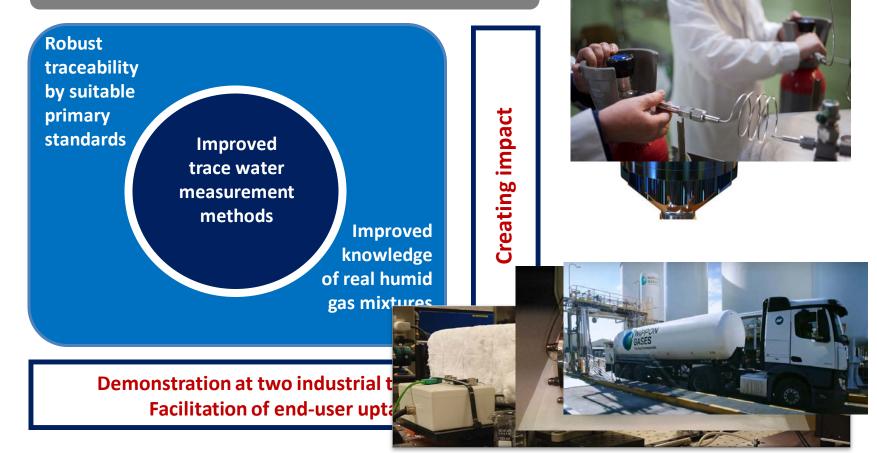


Project implementation





Stakeholder's Steering Board







Development and improvement of optical analysers

- Target: H_2O traces in Ar, N_2 , H_2 [from 5 ppm (-65 °C) to 5 ppb (-105 °C) @ 0.1 MPa].
- Relative uncertainty: 3 % (at 5 ppm) to 8 % (at 5 ppb)

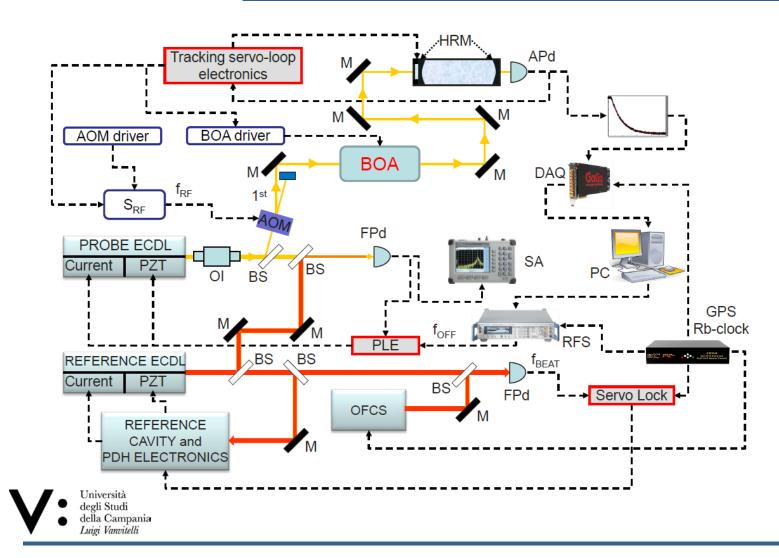
4x systems

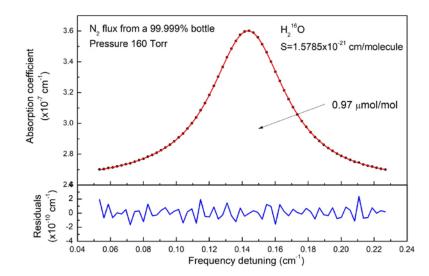
- Enhancements in NIR comb-calibrated frequency-stabilized cavity ring down spectrometer (CC-FS-CRDS);
- NIR cavity-enhanced frequency modulated (CE-FM) spectroscopy hygrometer development;
- □ Far-UV absorption spectroscopy system development;
- □ Upgrade of existing high-resolution FTIR system.



NIR comb-calibrated frequency-stabilized cavity ring down spectrometer (CC-FS-CRDS)







SI traceable uncertainty of 0.3% for line intensity

Contribution	Туре А	Туре В
(k=1)	(%)	(%)
Statistical	0.5 - 3	
Line strength		0.3
Frequency scale		Negligible
Line shape model		0.1
Gas temperature		0.05
Partition function		0.04
Pressure		0.1
Overall combined uncertainty	0.5 - 3.1 %	

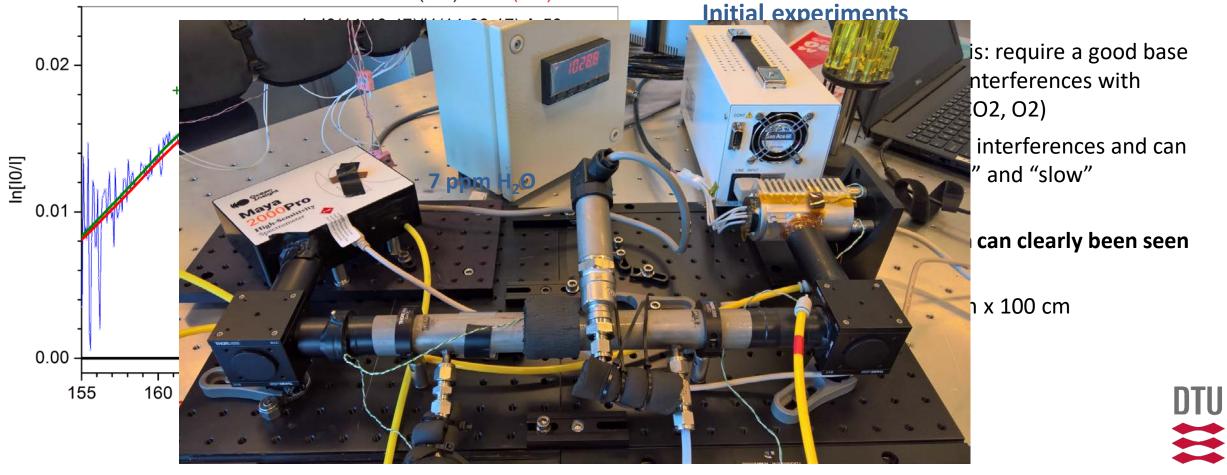


A compact and transportable far-UV system



H₂O Cross section

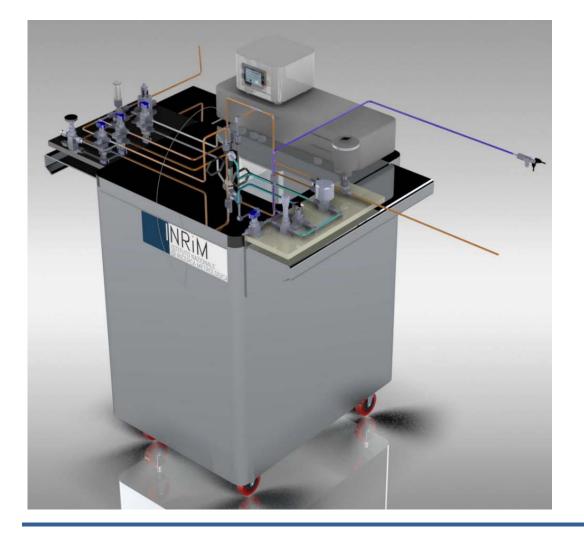
h2o traces in measurements with Ar with I0(60s) and I1(30s)





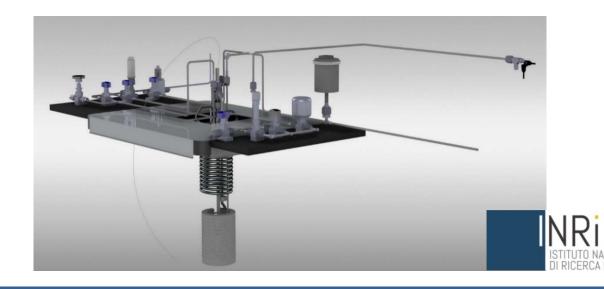
Robust traceability to trace water measurements in real humid gas mixtures





Range extension of the INRiM LFP generator

- Two-pressure, single-pass, humidity generator
- Frost-point temperature: -105 °C to -20 °C
- Water vapour mole fraction: 5 nmol/mol to 1 mmol/mol
- Pressure: 200 hPa to 0.5 MPa
- Carrier gas: Nitrogen, Argon

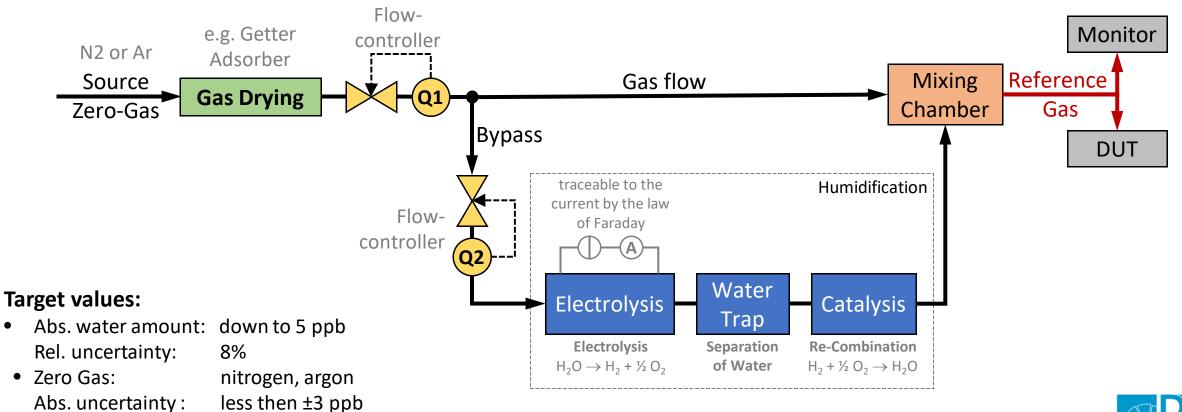




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Basic setup of the PTB Coulometric Trace Water Generator



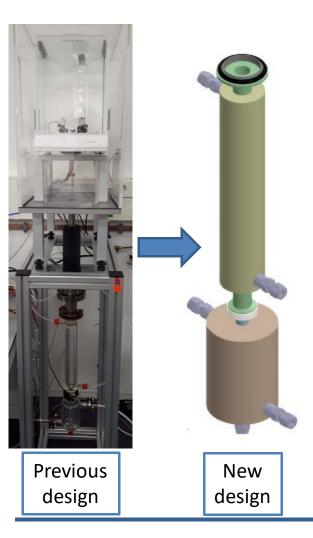






VSL permeation system based on a passivated magnetic suspension balance





Set up a permeation system based on a passivated magnetic suspension balance to generate primary standard of water amount fractions following ISO 6145-10 and ISO 6145-7.

- Target range: 50 nmol/mol up to 5 µmol/mol
- Matrix gases: N₂ and H₂

Testing and validation of the new system





New chamber



Measurement of the enhancement factor in selected humid gas mixtures

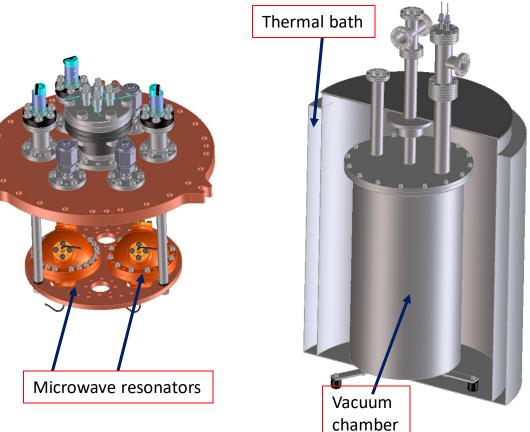


Goal: to improve the measurements for water vapour enhancement factor in nitrogen, argon and hydrogen at selected temperatures and pressures, in the frost-point temperature range between -90 °C and -30 °C and pressure range from 0.1 MPa to above 1 MPa.

CNAM new microwave-based hygrometer

- Design of the new microwave hygrometer system operating up to a pressure of 7-10 bar
- Completed the design of the new system (microwave resonators, the pressure vessel, the thermal shield and the vacuum chamber).
- The manufacturing procedure and the purchase process are in progress.





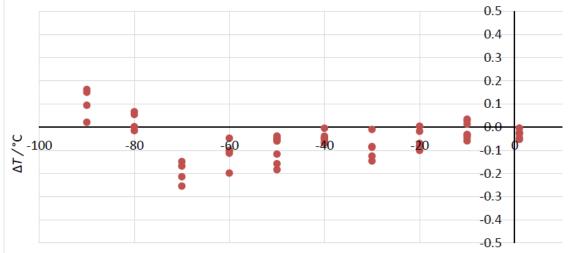


Transportable Frost Point Generator





System reproducibility



Achievements so far:

- Transportable frost point generator
- Flow rate 1-to-5 L/min on external closed loop
- Generated conditions down to -100°C fp
- Independent test data down to -90°C fp

FPG Set Point / °C Set Point - Generated Dew Point

Figure 2: Values of the difference, ΔT , between the FPG Set Point and the Generated dew-point temperature value as measured by a reference chilled-mirror hygrometer at each test point between -90 °C and +1 °C.







Key drivers

- Global market for industrial gas reached \$95 billion in 2019. It grew at 5 % per year.
- In Europe, in 2019, the gas market reached a value of about € 15 billion.
- European PV market is forecast for double-digit yearly growth. It grew by >100 % in 2019.
- OLEDs for next-generation flexible displays a booming market to be worth \$3 billion in near future.

Expected impact

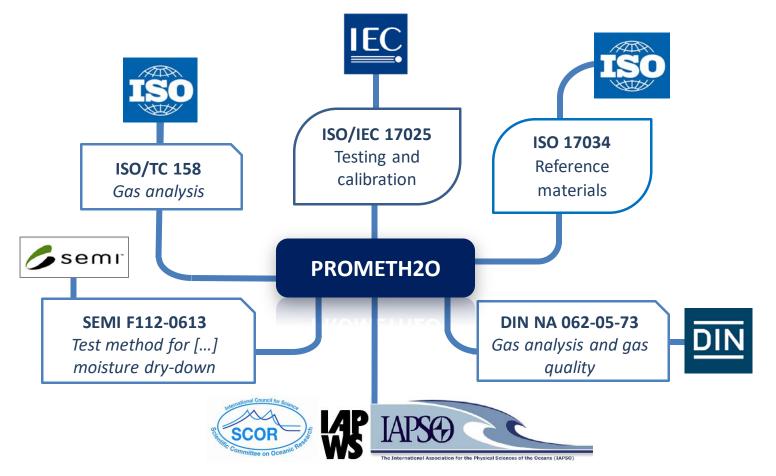
- Early industrial impact expected **on UHP gas manufacturing and supply.**
- Improved, traceable, measurements of trace water in UHP gas production and supplies to serve advanced industrial sectors.
- On site calibrations/checks using transportable references for improved process efficiency.
- To sustain **innovation and competitiveness** of European instrument makers and service providers.
- To contribute to **renewable and sustainable technologies** solar, PV, low-energy light sources, etc.



Impact on metrology and standards



- Extended-range primary standards and measurement traceability for trace water in UHP gases.
- Integration of metrology infrastructure in Europe and leadership of European NMIs in this developing field.
- **Underpinning of metrology** of trace water for wider reference gases (e.g. N₂, H₂, Ar).
- Better knowledge of measurement techniques and of real humid gas mixtures.
- A **CIPM key comparison** enabled in the trace water range.







A Steering Board (SB) made of key stakeholders, i.e., gas and equipment manufacturers, industry, standards developing organisations, international scientific associations has been established.







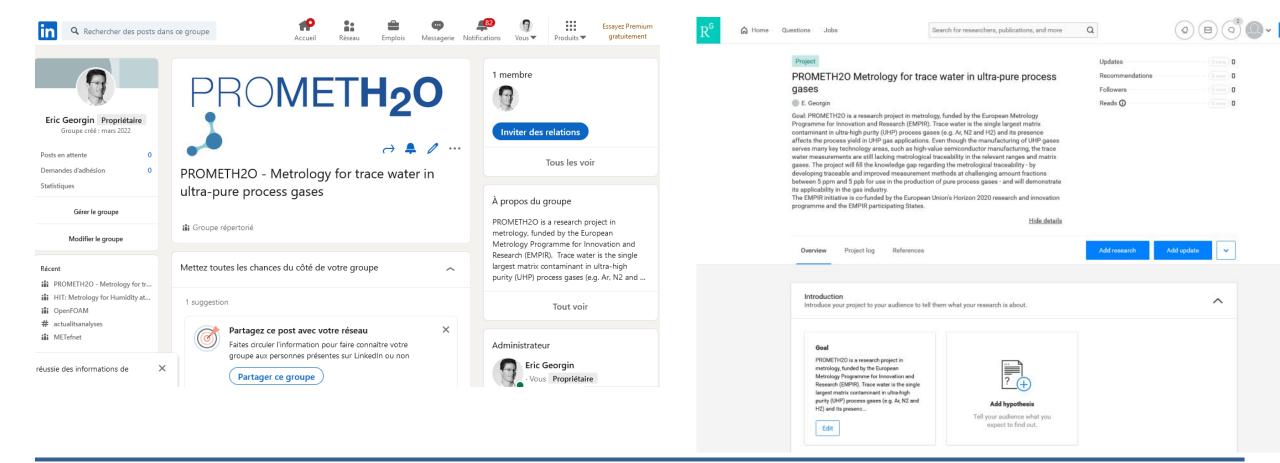
- Improve trace water measurement methods and techniques [in the range from 5 nmol/mol] to 5 μmol/mol].
- Provide robust traceability to trace water measurements by developing suitable standards down to 5 nmol/mol (-105 °C fp) in N₂, Ar and H₂.
- Improve the knowledge of thermophysical data (w.v. enhancement factor) of real humid gas mixtures.
- Demonstrate improved trace water measurement methods in industrially-relevant facilities.
- * Facilitate **the take up** of the technology and the European-wide measurement infrastructure.





LinkedIn

Research gate





Stay in touch





THE PROJECT

Metrology for trace water in ultra-pure process gases

Overview

Trace water is the single largest matrix contaminant in ultra-high purity (UHP) process gases. Even though the manufacturing of UHP gases serves many of the key technology areas, such as high-value semiconductor manufacturing, trace water measurements are still lacking measurement traceability in the relevant ranges and matrix gases.

READ MORE

www.prometh2o.eu

Thank you for your attention!